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Sheet 1 of 1

Form PTO-1449 (REV. 1/06)		US Dept. of Commerce PATENT & TRADEMARK OFFICE		ATTY DOCKET NO. 127579		10574511 APPLICATION NO. New U.S. National Stage of PCT/FR2004/002571	
INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary)				APPLICANTS Raphael SALOT et al.			
				FILING DATE April 3, 2006			
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EXAMINER		/Sean Cullen/			DATE CONSIDERED 05/05/2009		
Examiner: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.							

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